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SURFACE PREPARATION OF NIOBIUM FOR SUPERCONDUCTING QUBIT APPLICATIONS

ANTOINE PACCO

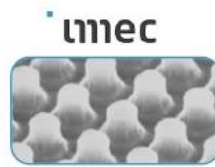
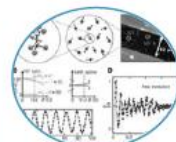
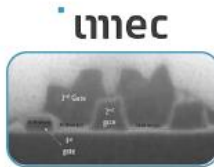
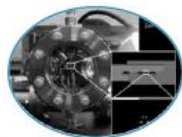
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SANCHEZ AND FRANK HOLSTEYNS

QUBIT DEVICE FOCUS @ IMEC

SEMI- & SUPER-CONDUCTING QB'S

	No issue
	Good enough
	Survivable
	Not clear, difficult
	Showstopper



Qubit Type	NMR	Ion traps/ atoms	semiconductor QD	N V in diamond ⁺	Superconduct. circuits	Optical qubits	Gatemon (Majorana)
Coherence/ gate time	OK 2E4	OK 6E7	OK -E7	OK -E7	OK 5E7	OK -E5	OK E5
2D array path	no	likely	Likely with extreme scaling	likely	yes	likely	maybe
Max qb #	14	73	2	2	21 (~2000)	2	1
Fabrication	chemistry	Maybe Si fab likely*	CMOS compatible	Random Single ion	Al/Al ₂ O ₃ /Al Si fab OK	OIO platform	CMOS compat Maybe
Device size	molecule	Atom but many lasers	transistor	Not clear	100s of um ²	mm ²	mm ²
other	Requires very large magnets	Requires lasers 4K	25mK	Requires lasers 4K	25mK	Deterministic 1-photon source; 4K	25mK

QUBIT COHERENCE

MOORE'S LAW FOR QUANTUM COHERENCE

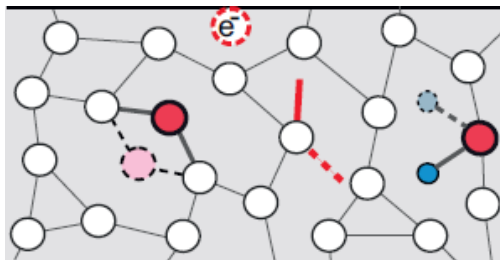
LOW LOSS =
HIGH Q-FACTORS



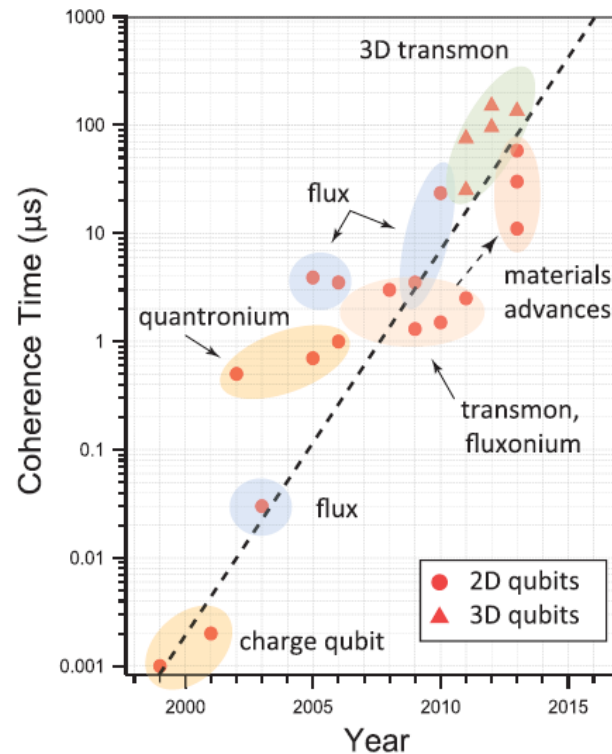
LONG
COHERENCE
TIMES



→ REDUCTION OF
TWO-LEVEL-SYSTEMS



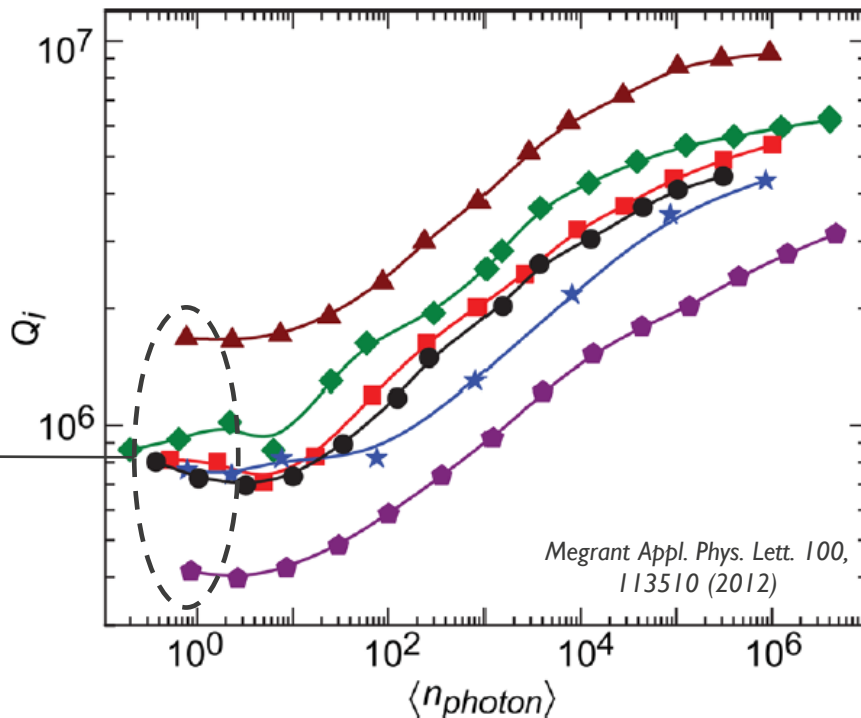
LISENFELD, SCIENTIFIC REPORTS MARCH 2016



WELANDER, MRS BULLETIN
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RESONATORS FOR DETECTION OF TLS'S

POWER DEPENDENCE OF THE INTERNAL QUALITY FACTOR Q_i

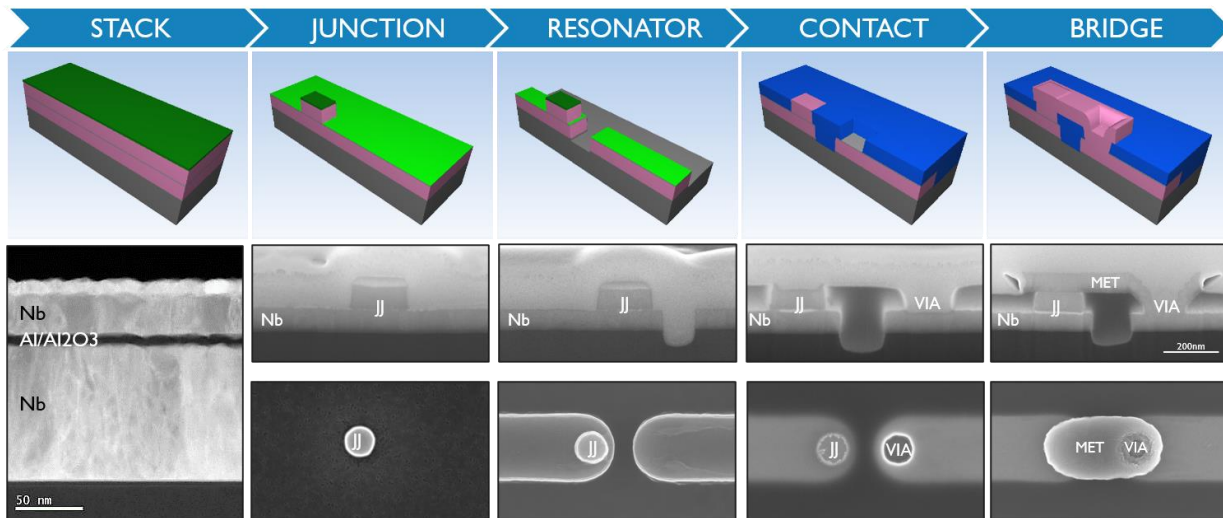


Low power ("single photon") regime is of interest to qubits

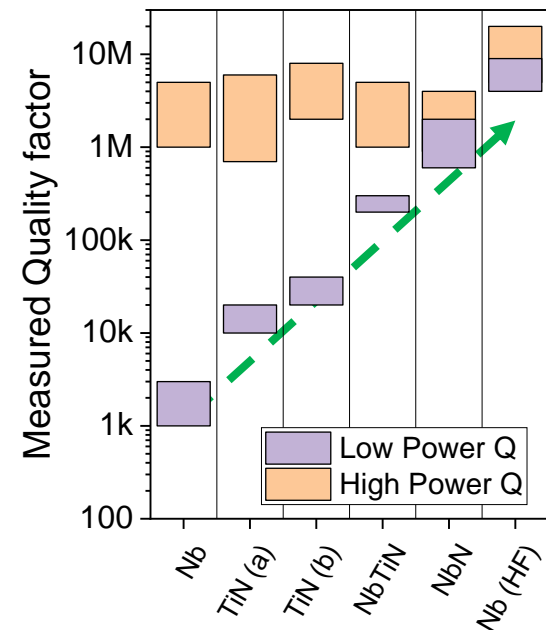
$Q_i \rightarrow$ measure for *MATERIAL* and *FABRICATION PROCESS* **QUALITY**

QB FABRICATION PROCESSES AND SC METALS

IMEC 300 mm wafer FAB QUBIT PROCESS flow:



FAB PROCESSES have an influence on SURFACES & INTERFACES



STRONG MATERIAL & PROCESS DEPENDENCE

NIOBIUM AS SUPERCONDUCTING METAL

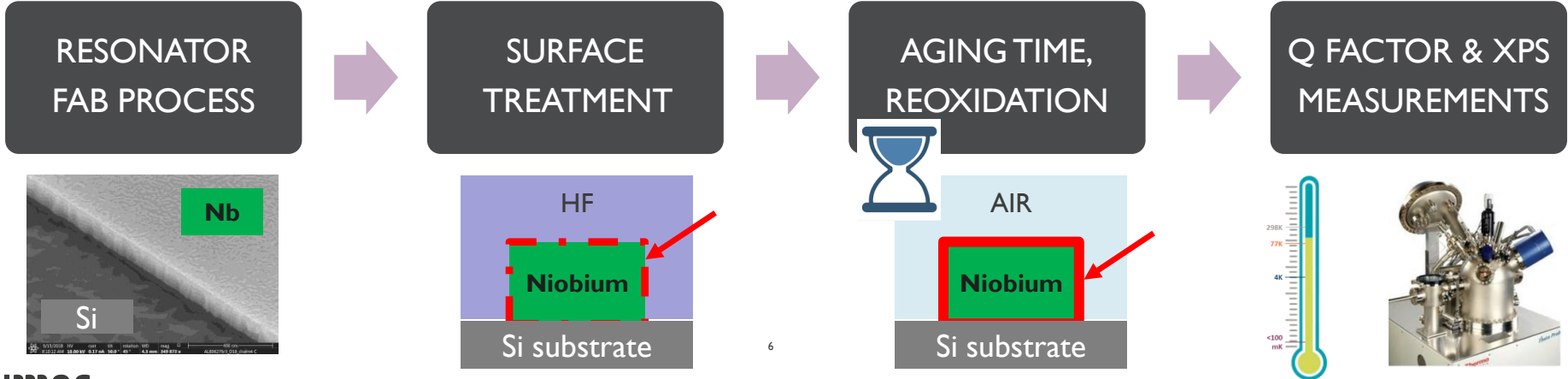
PRO Promising candidate for **VLSI** and high T_c at **9.2 K**.

CONTRA forms a **native oxide film** once exposed to **air** → detrimental TLS's

THIS STUDY



EXPERIMENTAL METHOD:

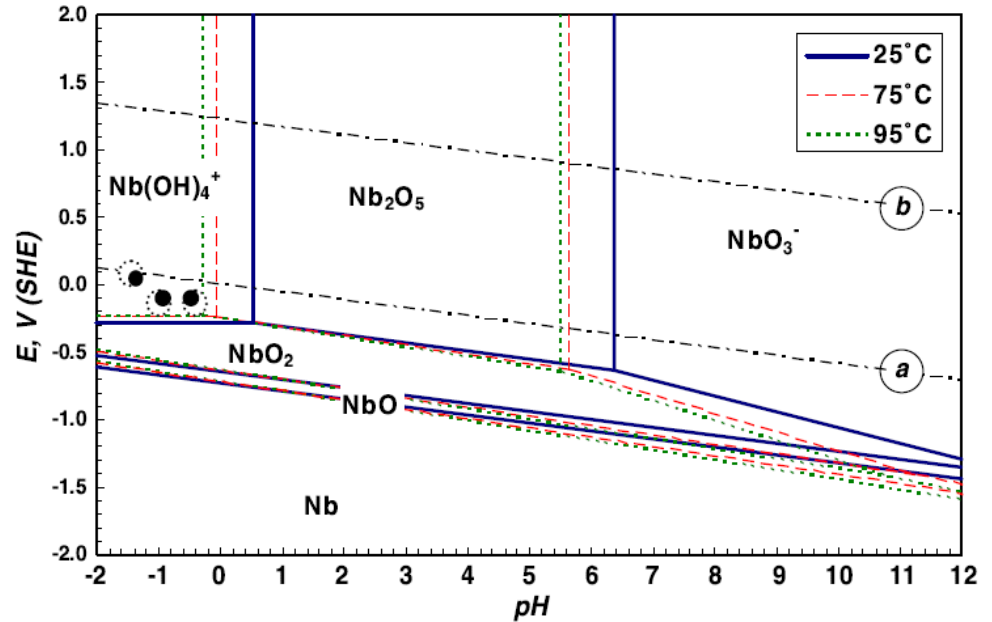


CHEMICAL PROPERTIES OF NIOBIUM

- Noble? **NO**
- Resistant to corrosion? **YES**

→ **EASY** to clean niobium

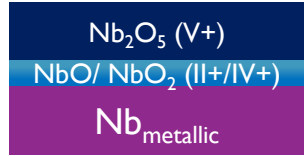
→ **DIFFICULT** to have niobium in its metallic form



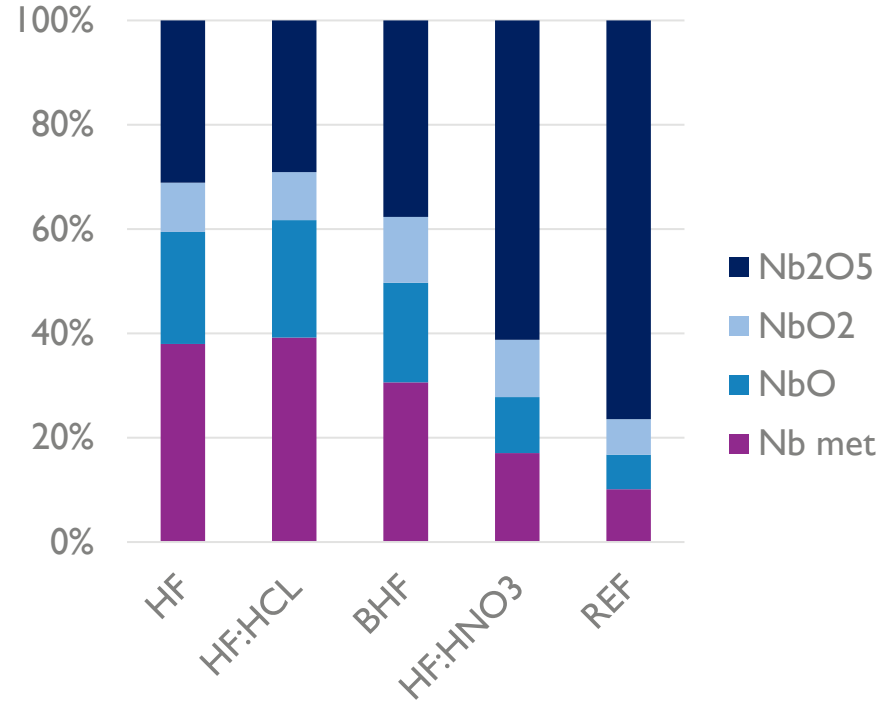
Asselin, E., Ahmed, T.M., and Alfantazi, A. (2007), "Corrosion of Niobium in Sulfuric and Hydrochloric Acid Solutions at 75 and 95 deg. C," *Corrosion Science*, **49**(2), pp 694-710.

CLEANING & ETCHING SOLUTIONS

ETCH RATE AND SURFACE COMPOSITION AFTER ETCH



Solution	Dip time (min)	Film loss (nm)	Etch Rate (nm/min)
HF	10	14.5	1.4
HF:HCl	10	10.4	1.0
BHF	10	2.3	0.2
HF:HNO ₃	3.5	61.8	17.7

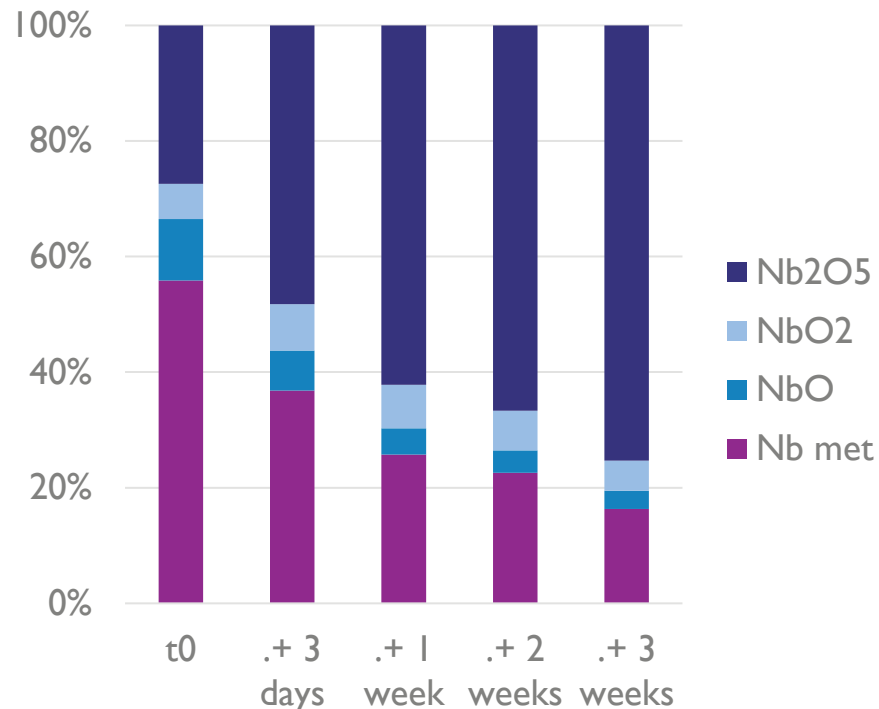
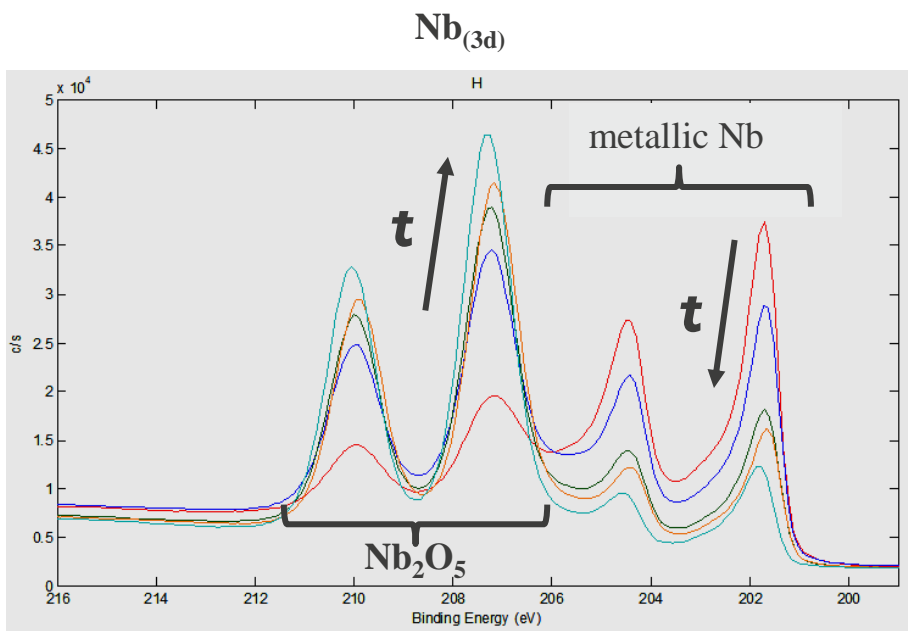
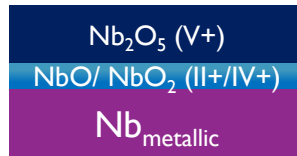


HF-based treatments etch Nb and decrease the Nb₂O₅ oxide.



RE-OXIDATION OF NIOBIUM (LONG TIMES)

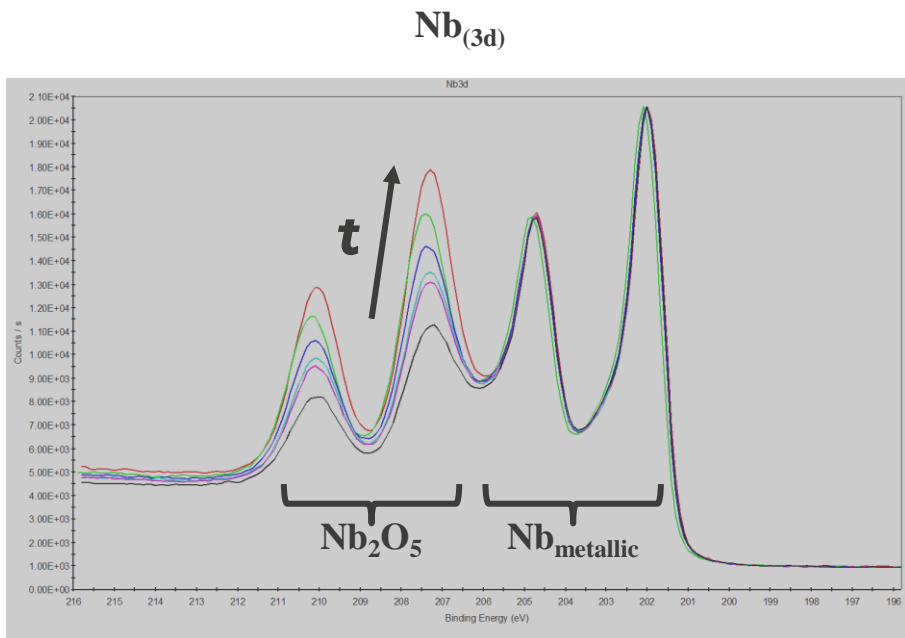
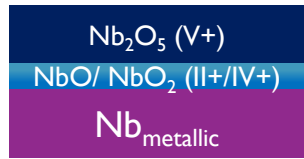
SURFACE COMPOSITION MONITORED BY XPS (AFTER HF-TREATMENT)



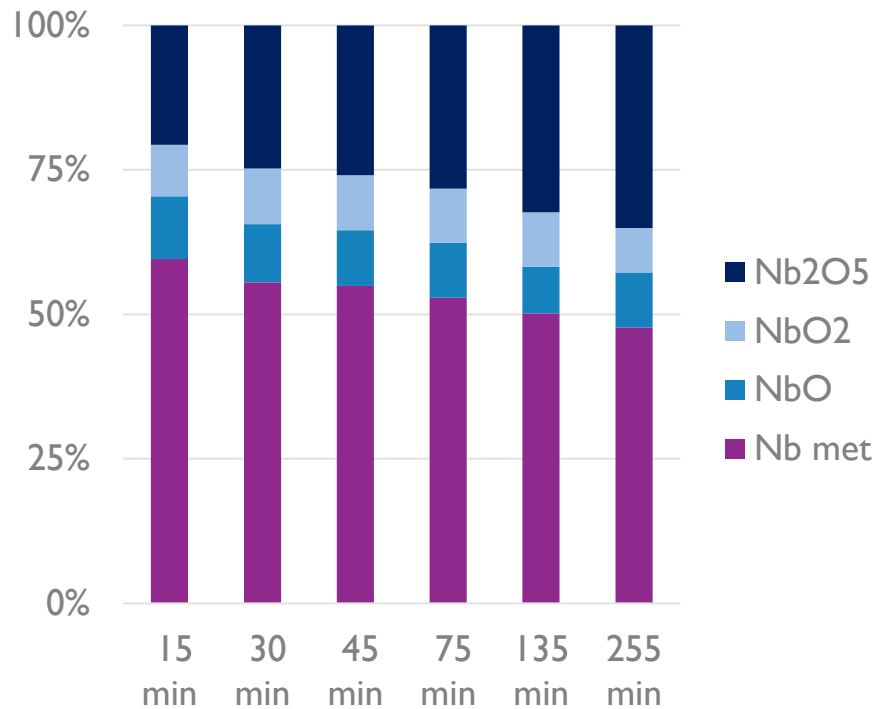
Nb gradually oxidizes to Nb_2O_5 oxide.
Sub-Ox decrease marginally a.f.o. time.

RE-OXIDATION OF NIOBIUM (SHORT TIMES)

SURFACE COMPOSITION MONITORED BY XPS (AFTER HF-TREATMENT)

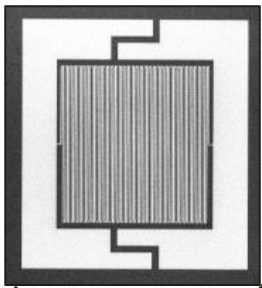


3 oxide types already present after the shortest ageing time !



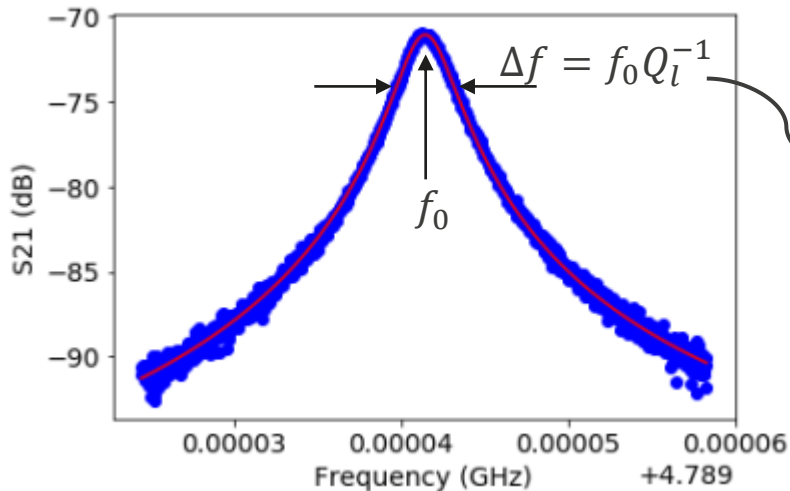
INTERNAL QUALITY FACTOR MEASUREMENTS

LE resonator



LE resonators in a 3D cavity

one of the LE resonances



Keep small by design

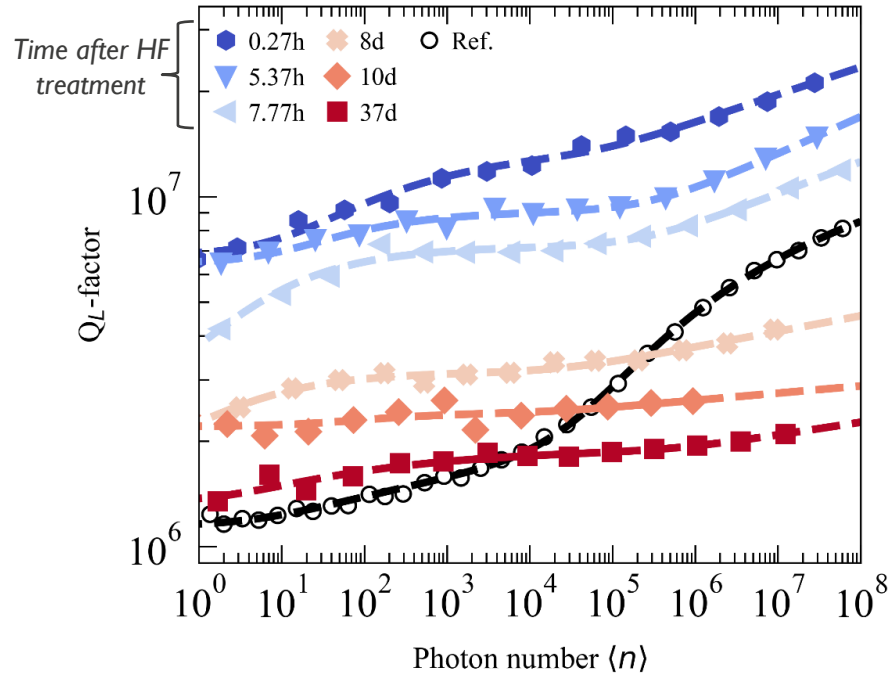
$$\frac{1}{Q_l} = \frac{1}{Q_{\text{ext}}} + \frac{1}{Q_{\text{int}}}$$

Measured Material dependent term of interest

↓

$$Q_l \sim Q_{\text{int}}$$

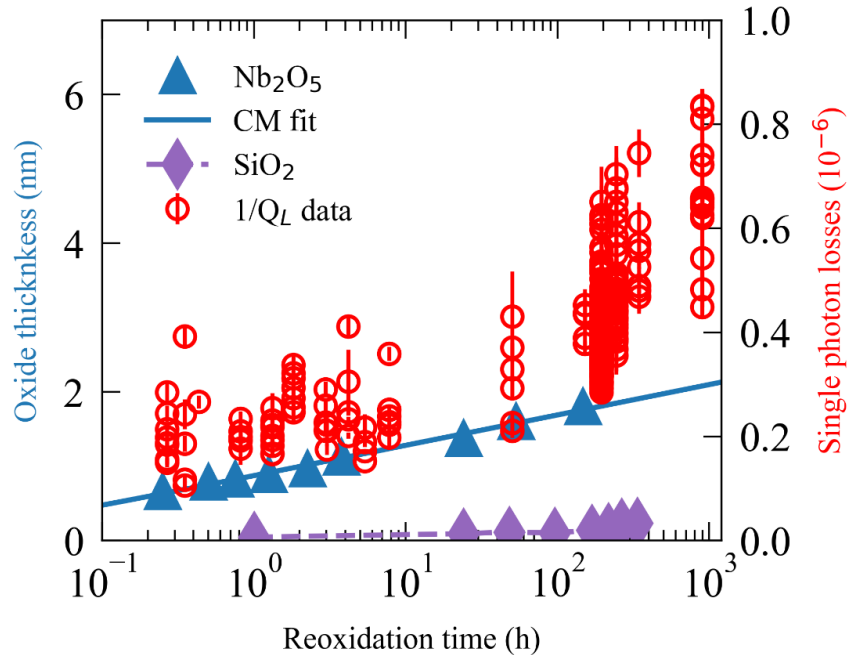
DEPENDENCE OF THE Q FACTOR ON RE-OXIDATION TIME



Verjauw J. et al. 300mm fab process for ultra high-quality superconducting resonators. IEDM paper, submitted.

- Q-factors increase after an HF treatment of the niobium resonators.
 - quality factors up to **7 million** in the single photon regime.
= highest reported for niobium !
- When niobium re-oxidation takes place, the Q-factors reduce again over time.

DEPENDENCE OF THE Q FACTOR ON Nb₂O₅ THICKNESS



Verjauw J. et al. 300mm fab process for ultra high-quality superconducting resonators. IEDM paper, submitted.

- The lower limit of $1/Q_L$ scales with the niobium oxide thickness.

→ Reduction of Nb₂O₅ thickness improves Q factor.
- Nb₂O₅ is the main source of loss in the single photon limit within the first ~200h.

SUMMARY

- An HF treatment partially removes the niobium(V) oxide.
- A decrease in Nb_2O_5 thickness has a huge effect on the quality factor of the niobium resonators:
 - Very high quality $Q_{s,\text{ph}} \sim 7\text{M}$ were measured for the lowest aging (re-oxidation) times.
- Losses increase again with Nb_2O_5 regrowth in time.

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